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<b>Session Title:</b>	<b>68. Flexible silicon and oxide TFT</b>
<b>Date:</b>	Aug. 26, 2016 (Friday)
<b>Time:</b>	13:00~14:30
<b>Room</b>	Room D (Samda B)
<b>Session Chairs</b>	Prof. Qun Zhang (Fudan Univ., China) Prof. Elvire Fortunato (New Univ. of Lisbon, Portugal)

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D68-1

13:00~13:25

**[Invited] Innovative Field Printed Wirable Universal Device for Integrated Circuit Design in Active Matrix Display Technology**

Yong-Sang Kim and Dong-Hoon Lee (Sungkyunkwan Univ., Korea)

D68-2

13:25~13:50

**[Invited] Surface-Potential Compact Model for Amorphous-IGZO Thin-Film Transistors**

Zhiwei Zong, Nianduan Lu, Ling Li, and Ming Liu (IMECAS, China)

D68-3

13:50~14:15

**[Invited] Introducing an All-New Spot-Beam-Based Laser-Crystallization Method for Manufacturing Advanced AMOLED Displays**

James S. Im (Columbia Univ., U.S.A.)

D68-4

14:15~14:30

**Calculation of Temperature Distribution in Si Films on Polyimide during Blue Multi-Laser Diode Annealing**

Tatsuya Okada, Yusuke Shizu, and Takashi Noguchi (Univ. of the Ryukyus, Japan)